Day: Wednesday



Date: 9/28/2005 Time: 16:04:56



## PALM INTRANET

## **Inventor Name Search Result**

Your Search was:

Last Name = KUNKEL First Name = GERHARD

Application#	Patent#	Status	Date Filed	Title	Inventor Name
<u>09161861</u>	6136660	150		STACKED CAPACITATOR MEMORY CELL AND METHOD OF FABRICATION	KUNKEL, GERHARD
<u>09163658</u>	Not Issued	161		DYNAMIC RANDOM ACCESS MEMORY LAYOUT	KUNKEL, GERHARD
<u>09250861</u>	Not Issued	164	02/17/1999	METHOD OF IMPROVING THE ETCH RESISTANCE OF PHOTORESISTS	KUNKEL, GERHARD
09272215	6211544	150	03/18/1999	MEMORY CELL LAYOUT FOR REDUCED INTERACTION BETWEEN STORAGE NODES AND TRANSISTORS	KUNKEL, GERHARD
09277669	6083788	150	03/26/1999	STACKED CAPACITOR MEMORY CELL AND METHOD OF MANUFACUTRE	KUNKEL, GERHARD
09282745	6379869	150		METHOD OF IMPROVING THE ETCH RESISTANCE OF CHEMICALLY AMPLIFIED PHOTORESISTS BY INTRODUCING SILICON AFTER PATTERNING	KUNKEL, GERHARD
<u>09407437</u>	6118683	150		DYNAMIC RANDOM ACCESS MEMORY CELL LAYOUT	KUNKEL, GERHARD
	6590657			SEMICONDUCTOR STRUCTURES AND MANUFACTURING METHODS	KUNKEL, GERHARD
09460700	6420272	150		METHOD FOR REMOVAL OF HARD MASK USED TO DEFINE NOBLE METAL ELECTRODE	KUNKEL, GERHARD
09522883	6365328	150	03/10/2000	SEMICONDUCTOR	KUNKEL,

				STRUCTURE AND MANUFACTURING METHOD	GERHARD
09561469	6511791	150	04/28/2000	MULTIPLE EXPOSURE PROCESS FOR FORMATION OF DENSE RECTANGULAR ARRAYS	KUNKEL, GERHARD
09561472	6451508	150	04/28/2000	PLURAL INTERLEAVED EXPOSURE PROCESS FOR INCREASED FEATURE ASPECT RATIO IN DENSE ARRAYS	KUNKEL, GERHARD
<u>09561581</u>	Not Issued	161	04/28/2000	Group connection of reticle sub- shapes to reduce line shortening and improve pattern fidelty	KUNKEL, GERHARD
09597116	Not Issued	161	06/20/2000	Buried bit line-shallow trench isolation defined active semiconductor areas	KUNKEL, GERHARD
09597123	6727989	150	06/20/2000	ENHANCED OVERLAY MEASUREMENT MARKS FOR OVERLAY ALIGNMENT AND EXPOSURE TOOL CONDITION CONTROL	KUNKEL, GERHARD
09598789	<u>6911687</u>	150	06/21/2000	Buried bit line-field isolation defined active semiconductor areas	KUNKEL, GERHARD
09602717	6383691	150	06/26/2000	Photomask and method for increasing image aspect ratio while relaxing mask fabrication requirements	KUNKEL, GERHARD
09603337	6282116	250	06/26/2000	Dynamic random access memory	KUNKEL, GERHARD
09609472	Not Issued	161	06/30/2000	CONCAVE SHAPED STACK CAPACITOR	KUNKEL, GERHARD
09801413	6558883	150	03/08/2001	APPARATUS AND METHOD FOR PATTERNING A SEMICONDUCTOR WAFER	KUNKEL, GERHARD
09916917	6606151	150	07/27/2001	GRATING PATTERNS AND METHOD FOR DETERMINATION OF AZIMUTHAL AND RADIAL ABERRATION	KUNKEL, GERHARD
09957937	6566219	150	09/21/2001	METHOD OF FORMING A SELF ALIGNED TRENCH IN A SEMICONDUCTOR USING A PATTERNED SACRIFICIAL LAYER FOR DEFINING THE	KUNKEL, GERHARD

		ļ.		TRENCH OPENING	
10406888	6842222	150	04/04/2003	METHOD OF REDUCING PITCH ON SEMICONDUCTOR WAFER	KUNKEL, GERHARD
10424039	6809800	150	04/25/2003	APPARATUS FOR PATTERNING A SEMICONDUCTOR WAFER	KUNKEL, GERHARD
10487911	Not Issued	30	08/13/2004	Photolithographic mask	KUNKEL, GERHARD
10637193	Not Issued	30	08/08/2003	Method for the characterization of an illumination source in an exposure apparatus	KUNKEL, GERHARD
10787118	Not Issued	30	02/27/2004	Phase-shift mask	KUNKEL, GERHARD
10870699	Not Issued	30	06/17/2004	Method for forming an opening on an alternating phase shift mask	KUNKEL, GERHARD
10965693	Not Issued	30	10/14/2004	Method for producing a mask adapted to an exposure apparatus	KUNKEL, GERHARD
11056402	Not Issued	20	02/14/2005	Method for producing a phase mask	KUNKEL, GERHARD
11065931	Not Issued	20	02/25/2005	Run to run control for lens aberrations	KUNKEL, GERHARD
11066638	Not Issued	20	02/25/2005	System for analyzing images of blazed phase grating samples	KUNKEL, GERHARD
11066913	Not Issued	30	02/25/2005	Optimizing focal plane fitting functions for an image field on a substrate	KUNKEL, GERHARD
11067191	Not Issued	20		Optimizing light path uniformity in inspection systems	KUNKEL, GERHARD
11170189	Not Issued	20	06/29/2005	Method for adapting structure dimensions during the photolithographic projection of a pattern of structure elements onto a semiconductor wafer	KUNKEL, GERHARD
60234502	Not Issued	159		Self aligned trench and method of forming the same	KUNKEL, GERHARD

Inventor Search Completed: No Records to Display.

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